

Supplementary information

Direct Storage of Holes in Ultrathin Ni(OH)₂ on Fe₂O₃ Photoelectrodes for Integrated Solar Charging Battery-type Supercapacitors

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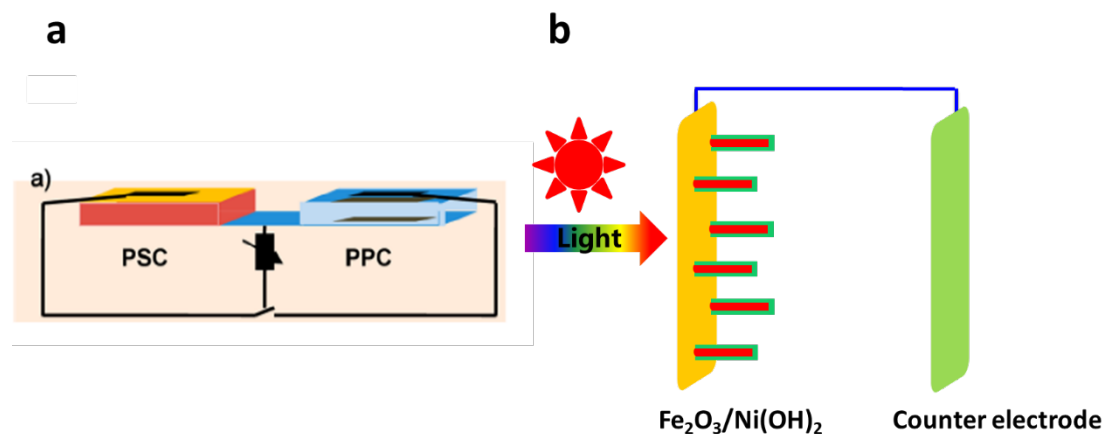


Fig. S1 Diagrammatic sketches of (a) a solar cell + supercapacitor¹ and (b) a photoelectrochemical supercapacitor

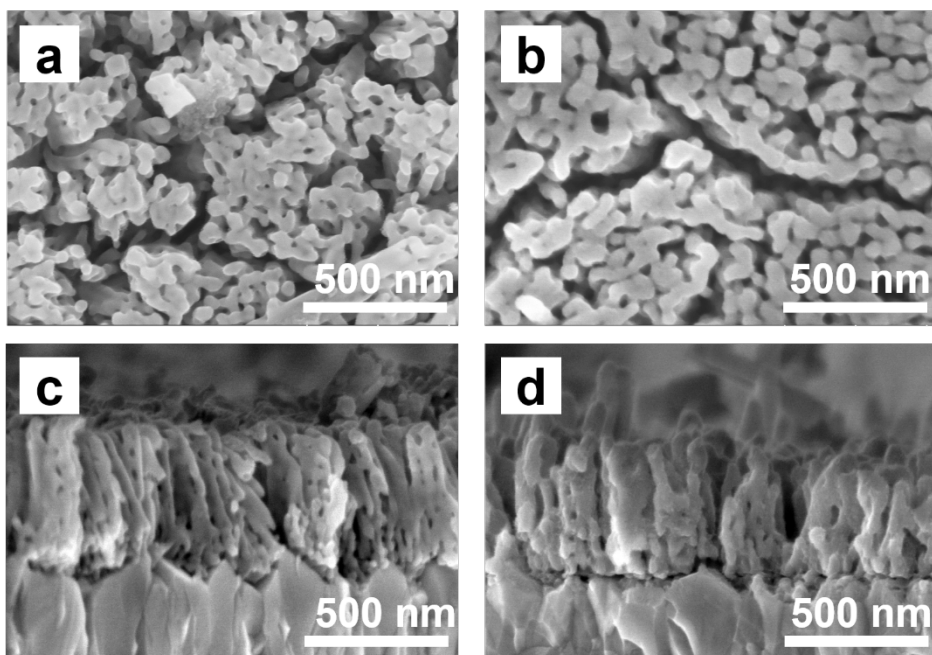


Fig. S2 Surface and cross-section SEM images of bare Fe_2O_3 (a, c) and $\text{Fe}_2\text{O}_3@$ $\text{Ni}(\text{OH})_2$ with deposition time of $\text{Ni}(\text{OH})_2$ for 10 min (b, d)

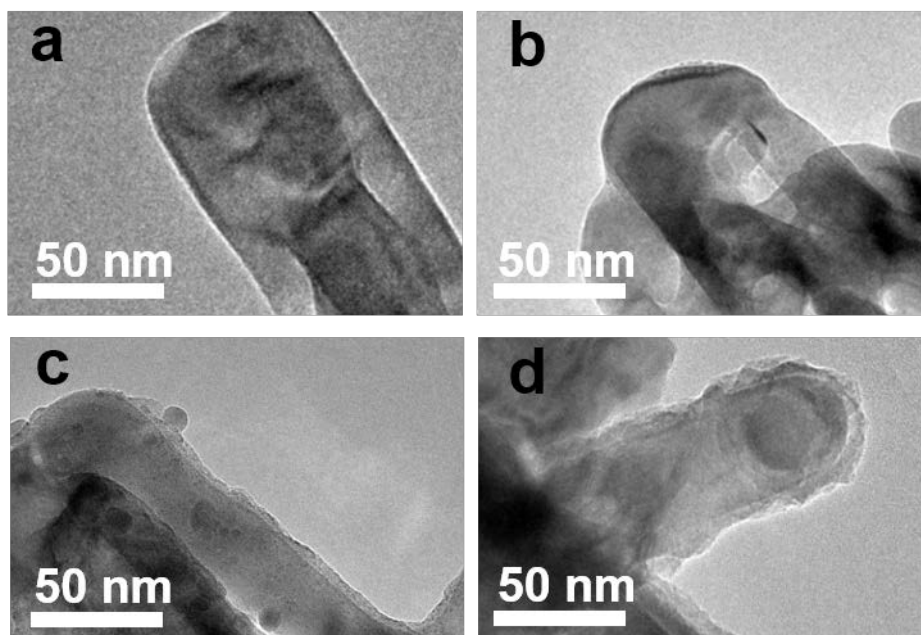


Fig. S3 TEM images of bare Fe_2O_3 (a) and $\text{Fe}_2\text{O}_3@$ $\text{Ni}(\text{OH})_2$ with different deposition time of $\text{Ni}(\text{OH})_2$ for 3 min (b), 5 min (c) and 10 min (d).

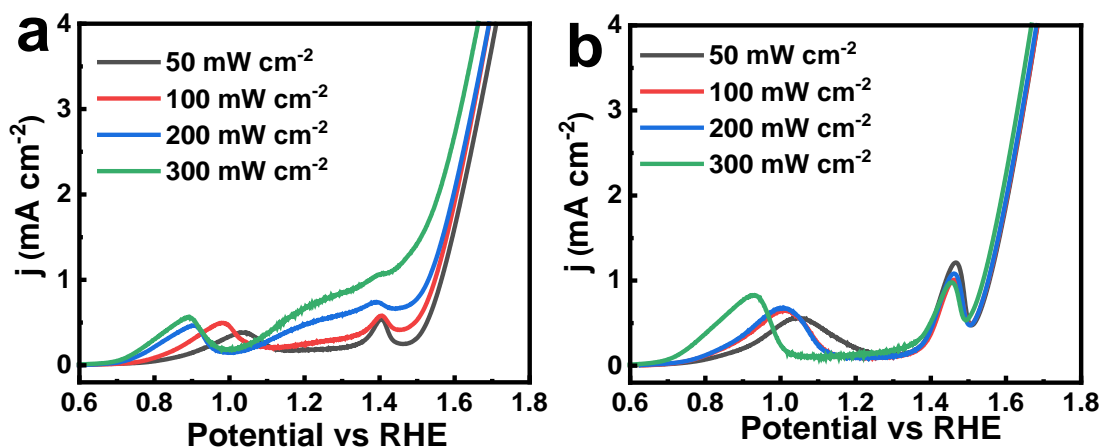


Fig. S4 Photocurrent-potential curves of $\text{Fe}_2\text{O}_3@\text{Ni}(\text{OH})_2$ with deposition time of $\text{Ni}(\text{OH})_2$ for 5 min (a) and 10 min (b) under illumination with different light intensities.

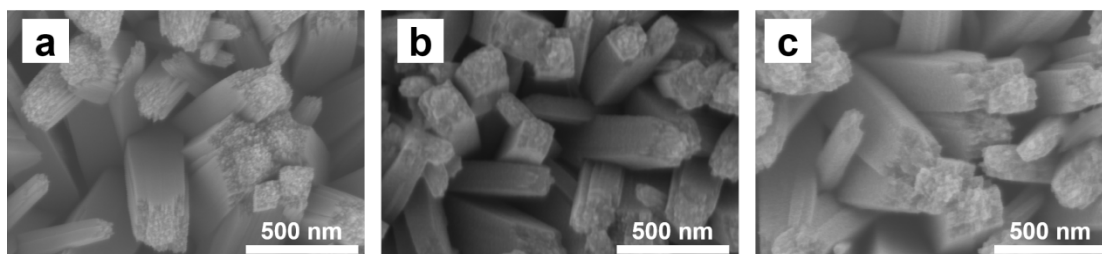


Fig. S5 Surface SEM images of bare TiO_2 (a) and $\text{TiO}_2@\text{Ni}(\text{OH})_2$ with deposition time of $\text{Ni}(\text{OH})_2$ for 5 min (b) and 10 min (c).

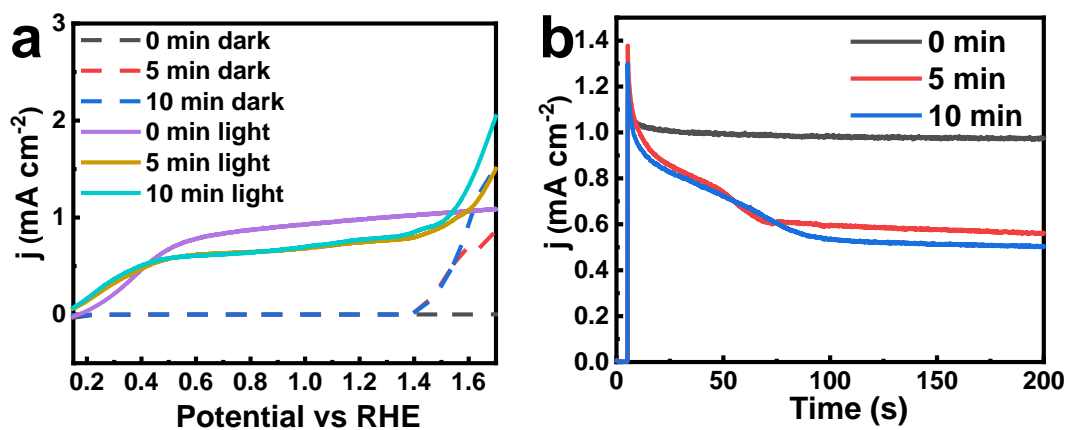


Fig. S6 (a) Dark current-potential and photocurrent-potential curves of bare TiO_2 and $\text{TiO}_2@\text{Ni}(\text{OH})_2$ with deposition time of $\text{Ni}(\text{OH})_2$ for 5 min and 10 min; (b) I-t curves at 1.1 V_{RHE} of $\text{TiO}_2@\text{Ni}(\text{OH})_2$ with deposition time of $\text{Ni}(\text{OH})_2$ for 10 min under illumination with different light intensities. Electrolyte: 1M KOH aqueous solution.

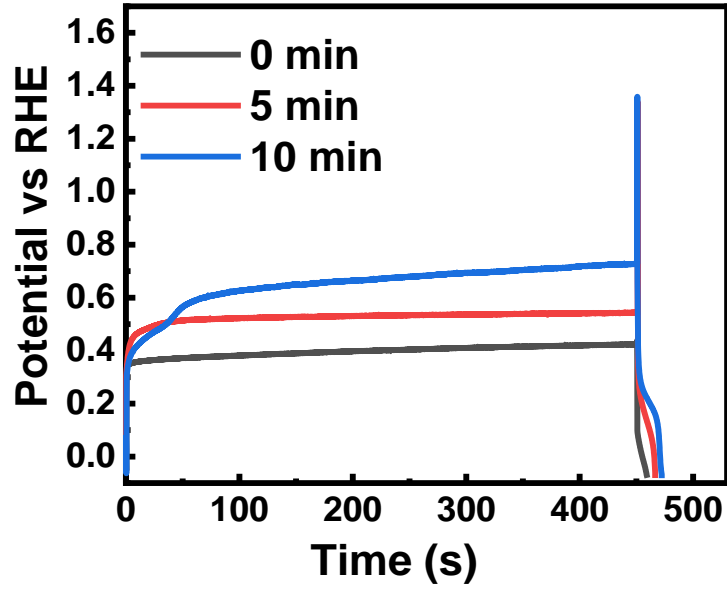


Fig. S7 Galvanostatic photo-charge at 0.6 mA cm^{-2} and dark-discharge curves of bare TiO_2 and $\text{TiO}_2@ \text{Ni(OH)}_2$ with depositon time of Ni(OH)_2 for 5 min and 10 min

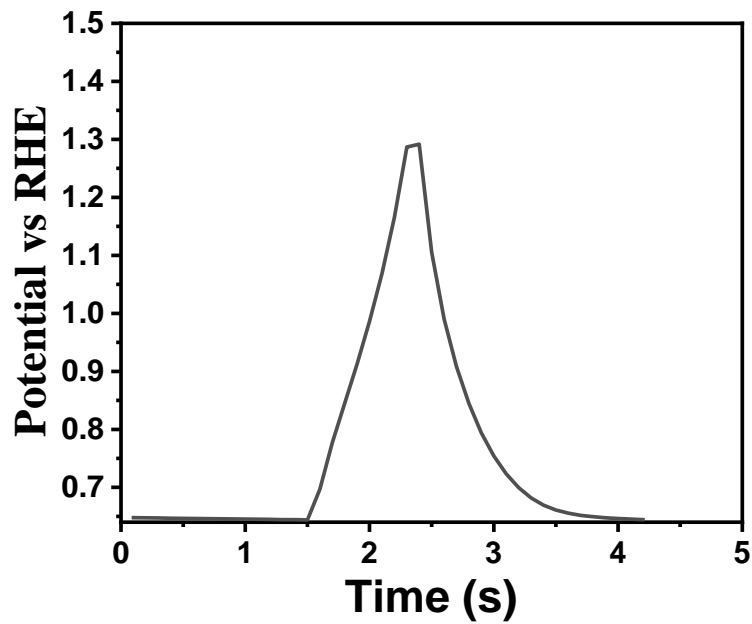


Fig. S8 Galvanostatic dark charge and discharge curves of $\text{Fe}_2\text{O}_3@ \text{Ni(OH)}_2$ with depositon time of Ni(OH)_2 for 10 min.

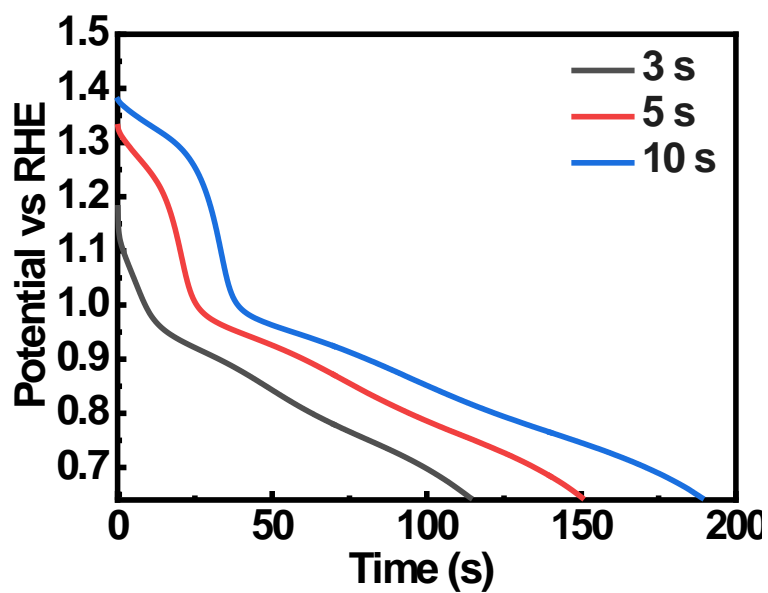


Fig. S9 Discharge curves at current density of 0.1 mA cm^{-2} of $\text{Fe}_2\text{O}_3@\text{Ni}(\text{OH})_2$ with deposition time of $\text{Ni}(\text{OH})_2$ for 10 min after photo-charge at $1.35 \text{ V}_{\text{RHE}}$ for different times.

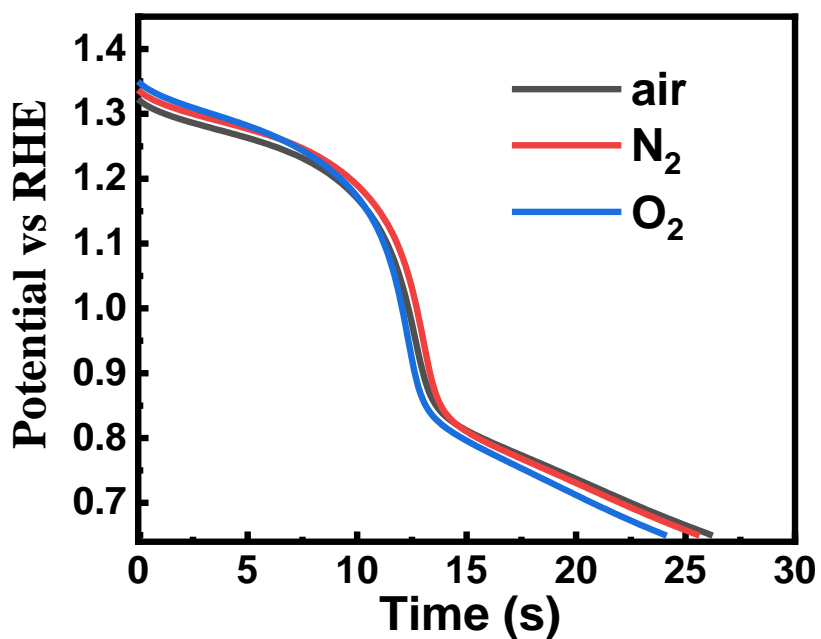


Fig. S10 Discharge curves (0.6 mA cm^{-2}) of $\text{Fe}_2\text{O}_3@\text{Ni}(\text{OH})_2$ with deposition time of $\text{Ni}(\text{OH})_2$ for 10 min at different atmosphere.

Table S1 The performances of different photo-capacitors in this study and literatures

Photoelectrochemical	Specific capacitance	Reference
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1. X. Xu, S. Li, H. Zhang, Y. Shen, S. M. Zakeeruddin, M. Graetzel, Y. Cheng and M. Wang. *ACS Nano* 2015, 9, 1782-1787.
2. S. Safshekan, I. Herraiz-Cardona, D. Cardenas-Morcoso, R. Ojani, M.Haro, S. Gimenez. *ACS Energy. Lett.* 2017, 2, 469-475.
3. J. Xu, H. Wu, L. Lu, S. Leung, D. Chen, X. Chen, Z. Fan, G. Shen and D. Li. *Adv. Funct. Mater.* 2014, 24, 1840-1846
4. J. Xu, Z. Ku, Y. Zhang, D. Chao and H. J. Fan. *Adv. Mater. Technol.* 2016, 1, 1600074
5. X. Chen, H. Sun, Z. Yang, G. Guan, Z. Zhang, L. Qiu and H. Peng. *J. Mater. Chem. A*, 2014, 2, 1897-1902
6. Y. Fu, H. Wu, S. Ye, X. Cai, X. Yu, S. Hou, H. Kafafy and D. Zou. *Energy Environ. Sci.* 2013, 6, 805-812.
7. F. Zhou, Z. Ren, Y. Zhao, X. Shen, A. Wang, Y. Y. Li, C. Surya and Y. Chai. *ACS Nano* 2016, 10, 5900-5908